This article was downloaded by:

On: 29 January 2011

Access details: Access Details: Free Access

Publisher Taylor & Francis

Informa Ltd Registered in England and Wales Registered Number: 1072954 Registered office: Mortimer House, 37-41 Mortimer Street, London W1T 3JH, UK



## Phosphorus, Sulfur, and Silicon and the Related Elements

Publication details, including instructions for authors and subscription information: http://www.informaworld.com/smpp/title~content=t713618290

Editorial board page for "Phosphorus, Sulfur, and Silicon and the Related Elements", Volume 85, Number 1-4

To cite this Article (1993) 'Editorial board page for "Phosphorus, Sulfur, and Silicon and the Related Elements", Volume 85, Number 1-4', Phosphorus, Sulfur, and Silicon and the Related Elements, 85: 1, a

To link to this Article: DOI: 10.1080/10426509308038174 URL: http://dx.doi.org/10.1080/10426509308038174

## PLEASE SCROLL DOWN FOR ARTICLE

Full terms and conditions of use: http://www.informaworld.com/terms-and-conditions-of-access.pdf

This article may be used for research, teaching and private study purposes. Any substantial or systematic reproduction, re-distribution, re-selling, loan or sub-licensing, systematic supply or distribution in any form to anyone is expressly forbidden.

The publisher does not give any warranty express or implied or make any representation that the contents will be complete or accurate or up to date. The accuracy of any instructions, formulae and drug doses should be independently verified with primary sources. The publisher shall not be liable for any loss, actions, claims, proceedings, demand or costs or damages whatsoever or howsoever caused arising directly or indirectly in connection with or arising out of the use of this material.

# Phosphorus, Sulfur, and Silicon and the Related Elements

Editor in Chief: R. R. Holmes

Department of Chemistry, University of Massachusetts, Amherst, Massachusetts 01003 U.S.A.

European Editor: L. Maier

R-1059, 6.08, CIBA-GEIGY AG. CH-4002, Basel, Switzerland

#### Associate Editors

**Editor Emeritus** 

W. Walter

University of Hamburg Institut für Organische Chemie Martin-Luther-King-Platz 6 D-2000 Hamburg 13, Germany

J. G. Verkade Department of Chemistry Iowa State University Ames, Iowa 50010, U.S.A.

L. Horner Mainz, Germany

(For Communications and Reviews)

#### **Editorial Board**

R. P. Arshinova Russian Academy of Sciences Kazan, Russia K. D. Berlin Oklahoma State University, Stillwater E. Block State University of New York at Albany

The University Frankfurt, Germany J. Y. Corey

University of Missouri, St. Louis R. Corriu

University of Science and Technology of Languedoc, France

Marquette University Milwaukee, Wisconsin

F. A. Davis Drexel University Philadelphia, Pennsylvania

S. A. Evans, Jr. University of North Carolina at Chapel Hill

L. Field Vanderbilt University Nashville, Tennessee

E. Fluck Gmelin Institute Frankfurt, Germany P. Gaspar

Washington University St. Louis, Missouri C. D. Hall

King's College

London, UK S. Husebye University of Bergen Norway

N. Inamoto University of Tokyo Japan

K. Jurkschat Martin-Luther University. Halle, Germany

J. F. King University of Western Ontario

O. I. Kolodiazhnyi Academy of Sciences of the Ukrainian SSR, Kiev, Ukraine S. S. Krishnamurthy

Indian Institute of Science,

Bangalore, India

J. P. Majoral Université Paul Sabatier Toulouse, France S. Masson Université de Caen

France T. A. Mastryukova Russian Academy of Sciences Moscow, Russia

F. Mathey Ecole Polytechnique Palaiseau, France

J. Michalski Polish Academy of Sciences, Lodz, Poland M. Mikolajczyk

Polish Academy of Sciences Lodz, Poland G. Modena The University

Padua Italy J. F. Nixon University of Sussex Brighton, UK

E. E. Nifant'ev V. I. Lenin State Pedag. Inst. Moscow, Russia

Institute of Heteroatom Chemistry Osaka, Japan

L. D. Quin University of Massachusetts Amherst

H. Roesky The University Gottingen, Germany

H. Sakurai Tohoku University Sendai, Japan

H. Schmidbaur Technical University Munich, Germany

A. Schmidpeter The University Munich, Germany

M. Schmidt The University Würzburg, Germany

R. Schmutzler The University Braunschweig, Germany

R. A. Shaw Birkbeck College London, UK R. Steudel

Technical University of Berlin, Germany

B. S. Thyagarajan The University of Texas at San Antonio

M. Veith Universität des Saarlandes, Germany

R. West University of Wisconsin, Madison

P. Wisian-Neilson Southern Methodist University Dallas, Texas

B. Wladislaw University of São Paulo, Brazil

R. Wolf Université Paul Sabatier Toulouse, France

Shanghai Institute of Organic Chemistry

H. Zimmer University of Cincinnati, Ohio R. A. Zingaro

Texas A&M University College Station B. Zwanenburg

University of Nijmegen The Netherlands

### Aims and Scope

Phosphorus, Sulfur, and Silicon and the Related Elements welcomes submissions involving the organic, inorganic, and biochemistry of phosphorus (including arsenic, antimony, and bismuth), sulfur (including selenium and tellurium), and silicon (including germanium and tin). In addition to research describing new chemistry of a particular element, especially welcome are presentations emphasizing relationships between elements and families of elements: for example, research comparing synthetic, mechanistic, or structural features providing new insight leading to a more rapid advance of science in these areas.

Original articles, communications, and selected reviews of broad interest will be considered for publication. Manuscripts may include illustrative material in color if this will enhance the presentation. There are no page charges and 25 free reprints will be supplied to the principal author. Regular papers may be sent to R. R. Holmes in Amherst or to L. Maier in Basel. Communications and reviews should be sent to W. Walter in Hamburg or J. G. Verkade in Ames.

Notes for contributors, including information on communications and reviews, can be found at the back of the journal.

#### General Information

Please see the inside back cover for information on subscription rates, photocopy license, and article reprints.

© 1993 Gordon and Breach Science Publishers S.A. All rights reserved.

No part of this publication may be reproduced or utilized in any form or by any means, electronic or mechanical, including photocopying and recording, or by any information storage or retrieval system, without permission in writing from the Publisher. Distributed by STBS-Publisher's Distributor.

**DECEMBER 1993** 

Printed in the United States of America.